

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/726,911	12/03/2003	Hong-Kook Min	8836-214 (IB12285-US)	8836-214 (IB12285-US) 4739	
22150	7590 01/24/2006		EXAMINER		
F. CHAU & ASSOCIATES, LLC 130 WOODBURY ROAD			LANDAU, MATTHEW C		
	Y, NY 11797		ART UNIT PAPER NUMBER		
			2815	2815	
			DATE MAILED, 01/24/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

•		Application No.	Applicant(s)				
		10/726,911	MIN ET AL.	(gray)			
	Office Action Summary	Examiner	Art Unit				
		Matthew Landau	2815				
	The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).							
Status							
 Responsive to communication(s) filed on <u>09 November 2005</u>. This action is FINAL. 2b) This action is non-final. Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i>, 1935 C.D. 11, 453 O.G. 213. 							
Dispositio	on of Claims						
5)⊠ (6)⊠ (7)⊠ (Claim(s) <u>1-16</u> is/are pending in the application. (a) Of the above claim(s) is/are withdray Claim(s) <u>8-16</u> is/are allowed. Claim(s) <u>1-3 and 5</u> is/are rejected. Claim(s) <u>4,6 and 7</u> is/are objected to. Claim(s) are subject to restriction and/or	vn from consideration.					
Application	on Papers						
9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority u	nder 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 							
2) Notice 3) Inform	of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (PTO-948) ation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal F 6) Other:	ate)-152) _.			

Art Unit: 2815

DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-3, and 5 are rejected under 35 U.S.C. 102(b) as being anticipated by Ogura et al. (US Pat. 6,388,293, hereinafter Ogura).

Regarding claims 1-3, Figure 19 of Ogura discloses a control gate pattern (132L/242L) disposed over a semiconductor substrate 10 and comprising a tunnel insulation pattern 132a (silicon oxide), a trap insulation pattern (132b) (silicon nitride), a blocking insulation pattern 132c (silicon oxide) and a control gate 242L, which are stacked (col. 18, lines 5-15 and col. 20, lines 19-21); a selection gate electrode 241 disposed over the semiconductor substrate at one side and extending over substantially the entire top portion of the control gate pattern; a gate insulation pattern 401/402/103 interposed between the selection gate electrode and the semiconductor substrate, and between the selection gate electrode and the control gate pattern; and a cell channel region 211/212 comprising a first channel region 212 defined in the semiconductor substrate under the control gate pattern and a second channel region 211 defined in the semiconductor substrate under the selection gate electrode.

Regarding claim 5, Figure 19 of Ogura discloses the thickness of the gate insulation pattern 401/402/103 (at region 103) is less than the sum of the thickness of the tunnel insulation pattern, the trap insulation pattern, and the blocking insulation pattern.

Art Unit: 2815

Allowable Subject Matter

Claims 4, 6, and 7 are objected to as being dependent upon a rejected base claim, but

Page 3

would be allowable if rewritten in independent form including all of the limitations of the base

claim and any intervening claims.

Claims 8-16 are allowed.

The following is an examiner's statement of reasons for allowance: the prior art of

record, either singularly or in combination, does not disclose or suggest the combination of

limitations including a first selection gate electrode disposed, in parallel to the first control gate

pattern, over the semiconductor substrate at one side and extending over substantially the entire

top portion of the first control gate pattern; and a second selection gate electrode disposed, in

parallel to the second control gate pattern, over the semiconductor substrate at one side and

extending over substantially the entire top portion of the second control gate pattern.

Any comments considered necessary by applicant must be submitted no later than the

payment of the issue fee and, to avoid processing delays, should preferably accompany the issue

fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for

Allowance."

Response to Arguments

Applicant's arguments with respect to claim 1 have been considered but are moot in view

of the new ground(s) of rejection.

Art Unit: 2815

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Matthew C. Landau whose telephone number is (571) 272-1731.

The examiner can normally be reached from 8:30 AM - 5:30 PM. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Kenneth Parker can be reached on (571) 272-2298. The fax phone numbers for the organization where this application or proceeding is assigned are (571) 273-8300 for regular communications and (571) 273-8300 for After Final communications.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

Art Unit: 2815

may be obtained from either Private or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should any questions arise regarding access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Matthew C. Landau

January 21, 2006

KENNETH PARKER SUPERVISORY PATÉNT EXAMINER